

Please find below and/or attached an Office communication concerning this application or proceeding.

•		Application No.	Applicant(s)	
		09/955,388	HWANG ET AL.	HWANG ET AL.
	Office Action Summary	Examiner	Art Unit	1
		Anh D. Mai	2814	1
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply				
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).  Status				
1)🛛	Responsive to communication(s) filed on 17.5	September 2001 .		
2a) <u></u>	This action is FINAL. 2b)⊠ Th	is action is non-final.		
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims				
4)🛛	Claim(s) $\underline{1-12}$ is/are pending in the application			
4a) Of the above claim(s) 1-4 is/are withdrawn from consideration.				
5) Claim(s) is/are allowed.				
6)⊠ Claim(s) <u>5-12</u> is/are rejected.				
7) Claim(s) is/are objected to.				
8) Claim(s) are subject to restriction and/or election requirement.				
Application Papers				
9) The specification is objected to by the Examiner.				
10)⊠ The drawing(s) filed on <u>17 September 2001</u> is/are: a)⊠ accepted or b)☐ objected to by the Examiner.				
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).				
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.				
If approved, corrected drawings are required in reply to this Office action.				
12)☐ The oath or declaration is objected to by the Examiner.				
Priority under 35 U.S.C. §§ 119 and 120				
13)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).				
a)⊠ All b)□ Some * c)□ None of:				
1. Certified copies of the priority documents have been received.				
	2. Certified copies of the priority documents	s have been received	in Application No	
<ul> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>				
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).				
<ul> <li>a) ☐ The translation of the foreign language provisional application has been received.</li> <li>15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.</li> </ul>				
Attachment(s)				
1) Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) 🔲 Notic	view Summary (PTO-413) Paper No se of Informal Patent Application (PT r:	
J.S. Patent and Tr. PTO-326 (Re		tion Summary	Part o	of Paper No. 4

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#### **DETAILED ACTION**

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## Election/Restrictions

- 1. During a telephone conversation with Ms. Lee May on June 27, 2002 a provisional election was made without traverse to prosecute the invention of Group II, claims 5-12.

  Affirmation of this election must be made by applicant in replying to this Office action. Claims 1-4 have been withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention.
- Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

## Claim Rejections - 35 USC § 102

- (e) the invention was described in-
- (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or
- (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).
- 3. Claims 5-8, and 10-12 are rejected under 35 U.S.C. 102(e) as being clearly anticipated by Linn et al. (U.S. Patent No. 6,380,084).

Linn teaches a method for manufacturing a semiconductor device as claimed including:

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forming an insulating layer (52) having a contact hole therethrough on a semiconductor substrate (40);

forming a diffusion barrier layer (56/60) on a surface of insulating layer (52) and on surfaces within the contact hole; and

forming a plug in the contact hole by forming a first sub-plug (64) that fills a lower portion of the contact hole and forming a second sub-plug (68) that fills an upper portion of the contact hole on the first sub-plug (64). (See Figs. 15-16).

With respect to claim 6, the formation of the first sub-plug (64) of Linn comprises forming a first metal layer (64) on the insulating layer (52) having the contact hole (66) therethrough and etching back the first metal layer (64) to a predetermined depth (85) to expose a void in the first metal layer, if any.

With respect to claims 7 and 8, the formation of the second sub-plug (68) of Lin comprises forming a second metal layer (68) on the semiconductor substrate on which the first sub-plug (64) has been formed and polishing the second metal layer (68) so as to expose a top surface of the diffusion barrier layer (56/60) on the insulating layer (52).

With respect to claim 10, the second sub-plug of Linn is formed of a material as claimed.

With respect to claim 11, the second sub-plug (68) is formed to a thickness as claimed.

With respect to claim 12, the diffusion barrier layer (56/60) is formed of a material as claimed.

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# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over Linn '084 as applied to claim 5 above, and further in view of Lee et al. (U.S. Patent No. 5,801,096).

Linn teaches formed the first sub-plug (64).

Thus, Linn is shown to teach all the features of the claim with the exception of using tungsten.

However, Lee teaches that using tungsten (10/16) to fill the contact plug (9) are well known in the art to form a conductive plug.

Therefore, it would have been obvious to one having ordinary skill in the art at the time of invention to form the first sub-plug (64) of Linn using tungsten as taught by Lee to provide electrical contact to the lower portion of the semiconductor substrate.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anh D. Mai whose telephone number is (703) 305-0575. The examiner can normally be reached on 8:30AM-5:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on (703) 306-2794. The fax phone numbers for the

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organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

A.M June 27, 2002

> OLIK CHAUDHURI SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800